DEMINION FOR EVE	ENGLON OF TIME LINE	VER 27 CER 1 126(A)	Docket No.							
PETITION FOR EXT	SLA0733									
In Re Application of:	(Large Entity)	eng Hsu, Douglas J. Twee								
wyphostore or	Tong barr Loo, Onelly 16	g, _ oug.co o. 1 1100	•							
Serial No	Filing Date	Examiner Thomas J. Magee	Group Art Unit 2811							
10/602,436	June 23, 2003	THOMAS O. MAYER]							
Invention: Strained Silico	oni FinFET Device	<u>l</u> .	<u> </u>							
- Juganija Calot										
•										
TO THE COMMISSIONER FOR PATENTS:										
*** *********************************	ovisions of 37 CFR 1.136(a) to		sponse to the Office Action							
This is a request under the proof 06/04/2004 in the above ide	entified application.	eviend the bened to tilling a ter	·							
	s as follows (check time period	desired):								
One month		e Months Four Months	Five Months							
from: 09/04/04	until:	11/04/04								
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The fee for the extension of time is \$430.00 and is to be paid as follows:										
A check in the amount of the fee is enclosed.										
x The Commissioner is hereby authorized to charge any fees which may be required, or credit any										
	Deposit Account No. 19-1457 of this sheet is enclosed									
	tension of time is required, plea	se consider this a petition there	fore and charge any							
	lich may be required to Deposit		•							
	of this street is enclosed.	. *								
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1 / June >	Signature	Dated: November	T, 600T							
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David C. Ripma, Patent Co		•	•							
Sharp Laboratories of Ame 5750 NW Pacific Rim Bou										
Camas, WA 98607										
Phone: (360) 834-8754										
Facsimile: (360) 817-8505	5	•								
CC:										

PETITION FOR EXTENSION OF TIME UNDER 37 CFR 1.136(A) (Large Entity)						Docket No.	042	
In Re Applica	tion of:	Jong-Jan Lee, S		eng Hsu, D	ouglas J. Two	eet, and		
Serial N 10/602,4		Filing Date June 23, 200			xaminer as J. Magee		Group Art Unit 2811	
Invention: Si	trained Silico	 oni FinFET Device			<u></u>			
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of 06/04/2004 in t	he above id	ovisions of 37 CFR 1. entified application.		-	eriod for filing a	response	to the Office Action	on :
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X The Coverpa overpa A dupl X If an a addition	ommissione syment, to D icate copy o dditional ext mal fees wh	ount of the fee is enck r is hereby authorized eposit Account No. 19 if this sheet is enclose ension of time is requ ich may be required to f this sheet is enclose	to charge 9-1457 ed. ired, pleas o Deposit /	se consider t	this a petition the			
Ham	MC	Signature	4	Date	d: Novembe	r 4, 200	4	
David C. Ripma Sharp Laborator 5750 NW Pacifi Camas, WA 986 Phone: (360) 83 Facsimile: (360	ies of Ame c Rim Bou 607 4-8754	rica, Inc.						
CC.								